

Super-resolving Properties of Metalodielectric Stacks

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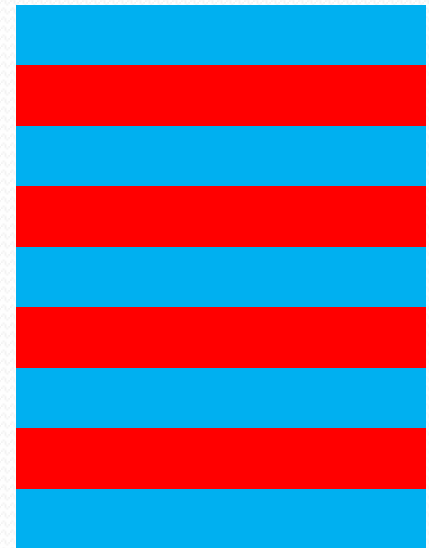
1 Introduction

Conventional optical imaging systems resolve only to about half the wavelength of incident light.

Goals

- UV-Vis wavelengths (400 – 700 nm)
- %T 100x greater than single layer Ag
- $\lambda/12$ spatial resolution

Operation of MDS



Suppress diffraction
through balance of
positive and
negative refraction

2 Transmission and Super-resolution regimes

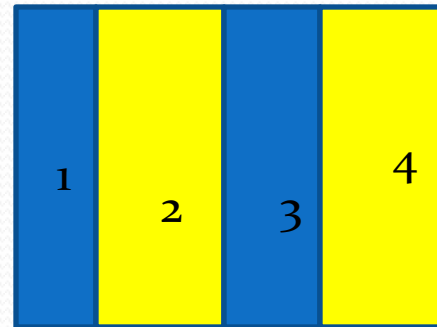
TMM formalism

$$E = (A_\alpha \exp(-i \beta_\alpha z) + B_\alpha \exp(i \beta_\alpha z)) \exp(-i \kappa x)$$

$$R = \left| \frac{f_{21}}{f_{11}} \right|^2, T = \left| \frac{1}{f_{11}} \right|^2$$

$$\begin{bmatrix} A_1 \\ B_1 \end{bmatrix} = \frac{1}{t_{12}} \begin{bmatrix} 1 & r_{12} \\ r_{12} & 1 \end{bmatrix} \begin{bmatrix} A_2 \\ B_2 \end{bmatrix} = T \begin{bmatrix} A_2 \\ B_2 \end{bmatrix}$$

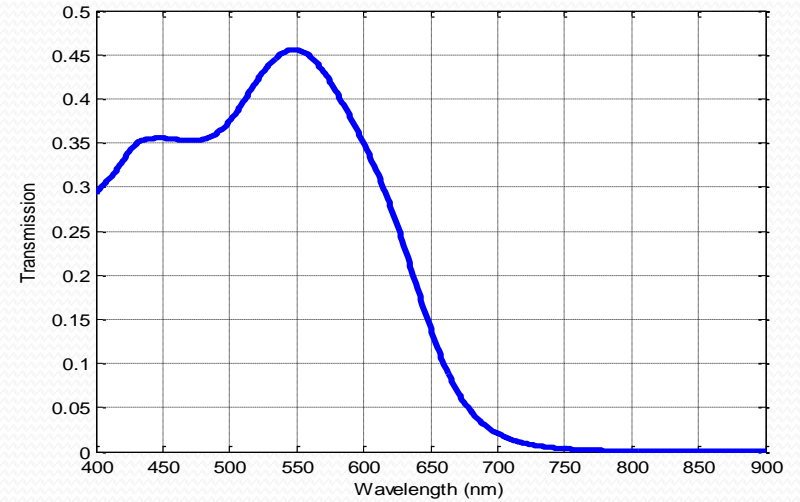
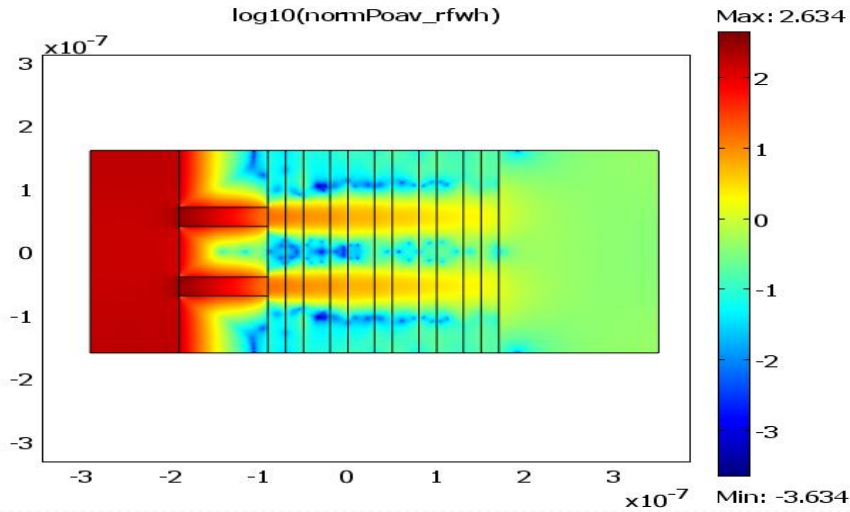
$$\begin{bmatrix} A \\ B \end{bmatrix} = \begin{bmatrix} \exp(i \phi) & 0 \\ 0 & \exp(-i \phi) \end{bmatrix} \begin{bmatrix} A' \\ B' \end{bmatrix} = P \begin{bmatrix} A' \\ B' \end{bmatrix}$$



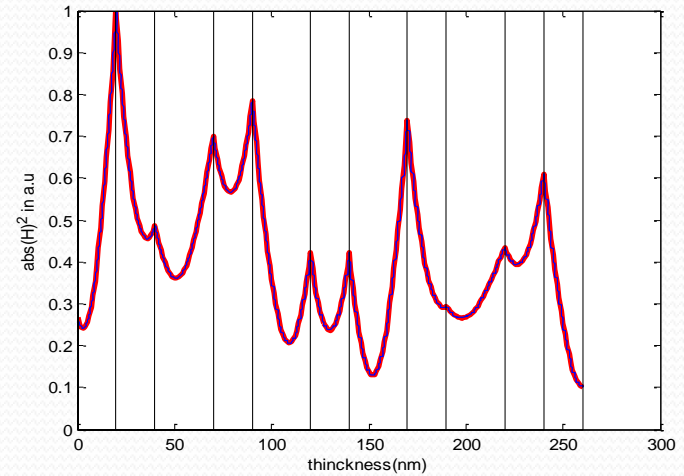
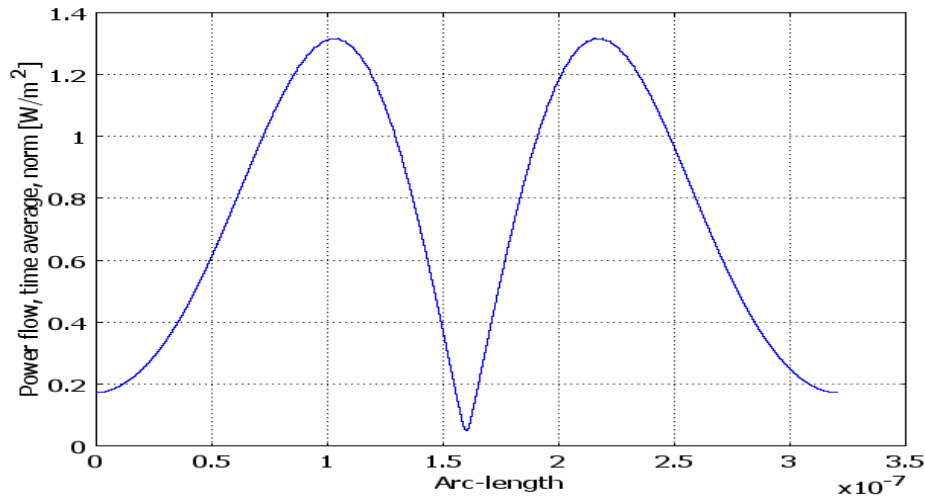
$$F = T_1 P_1 T_2 P_2 T_3 P_3 \dots T_n P_n T_{n+1}$$

$$F = \begin{bmatrix} f_{11} & f_{12} \\ f_{21} & f_{22} \end{bmatrix}$$

MDS₁



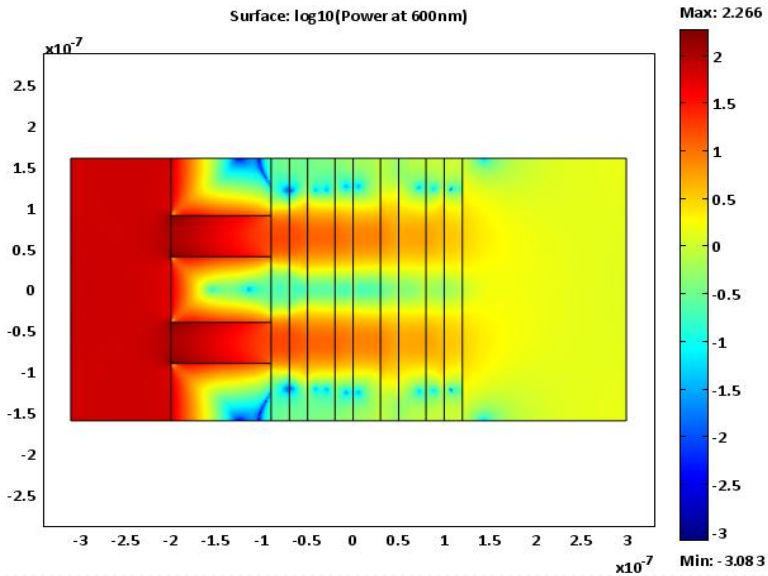
MDS₁: [GaP (20nm)/ 4.5 periods of Ag (20nm)/ GaP (30nm) /GaP (20nm)].



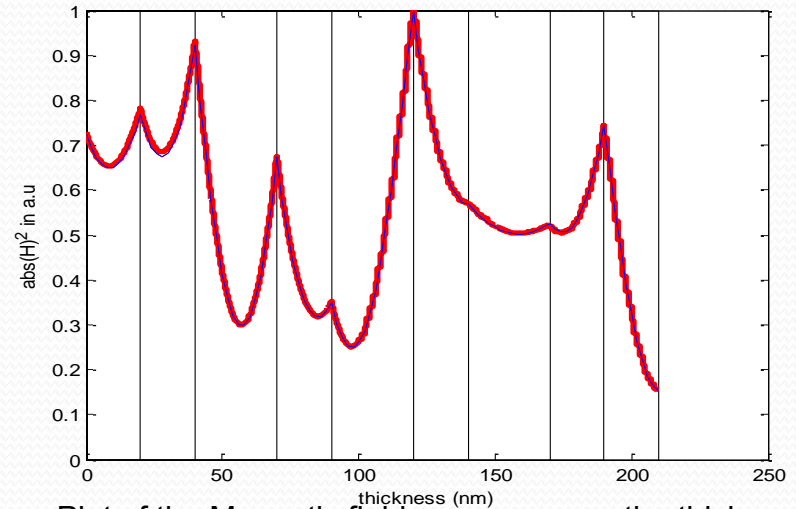
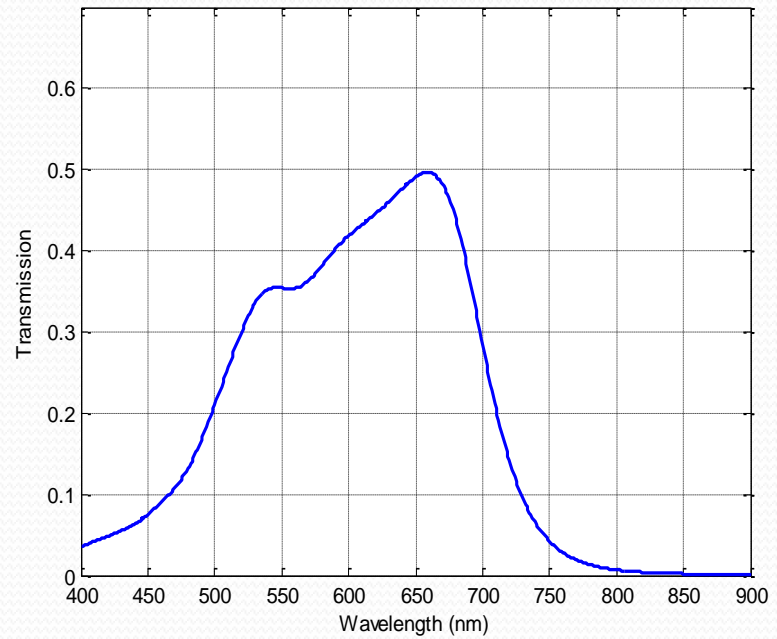
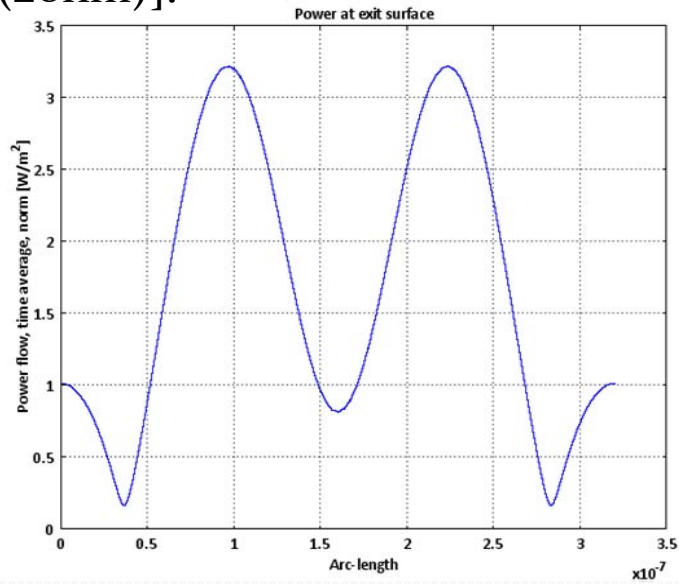
Plot of the Magnetic field squared across the thickness of MDS₁ consisting of Ag and GaP layers. There is an overlay of the red line over the blue line. **The red line is the FEM simulation**. While the blue line is TMM solution. Both methods give a transmission of 44% at an incident wavelength of 532nm.

MDS₂

Surface: $\log_{10}[\text{Power at } 600\text{nm}]$

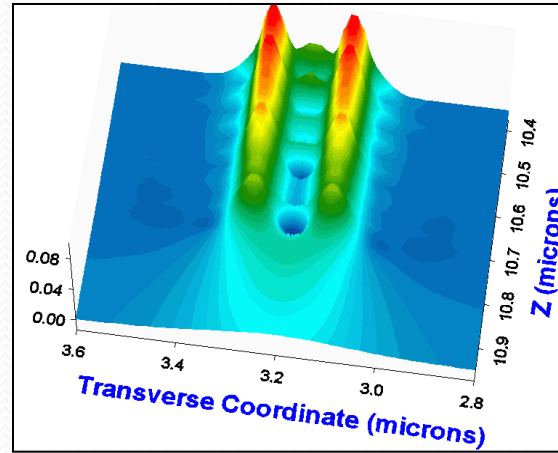
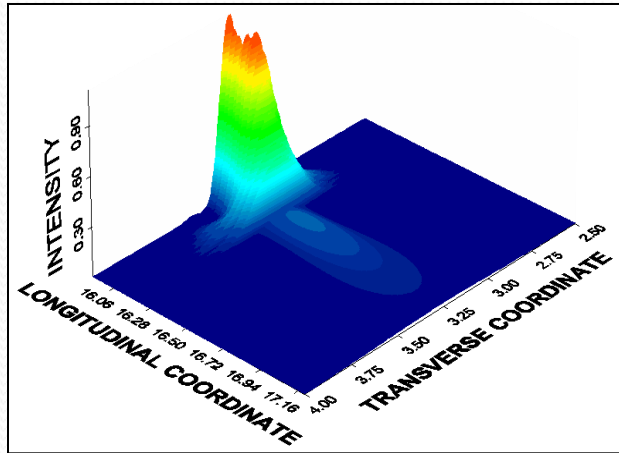


MDS₂: [GaP (20nm)/3.5periods (Au (20nm)/GaP (30nm))/GaP (20nm)].



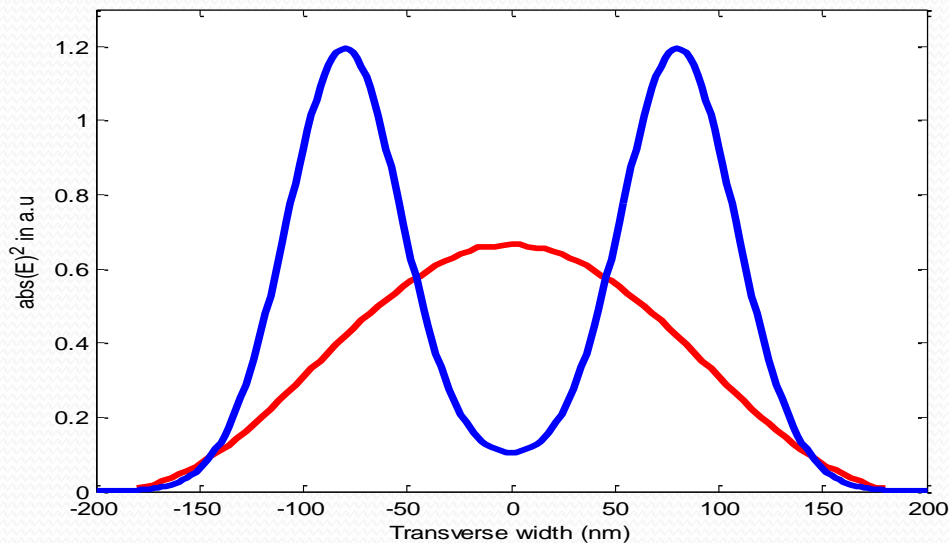
Plot of the Magnetic field square across the thickness of MDS₂ consisting of Au and GaP layers. There is an overlay of the red line over the blue line. **The red line is the FEM simulation**. While the blue line is TMM solution. Both methods give a transmission of 42% at an incident wavelength of 600nm.

Beam Propagation results (Plane-wave method)



Transmission through a MD photonic crystal (the layers are parallel to the transverse coordinate) in the focusing regime ($\lambda=400$ nm), which shows the formation of an external focal spot (left), and in the super-resolving regime (right) showing the super-guiding regime ($\lambda=640$ nm), with two closely spaced $\lambda/20$ channels that do not interfere thanks to the formation of transverse Plasmon waves [4,7].

MDS₃: Limitations of TMM



MDS₃: [TiO₂ (40nm)/ 3.5periods of (Cu (20nm)/TiO₂ (80nm)/TiO₂ (40nm))].

Comsol result: No Super-resolution Diffraction, unsuppressed.

Reason for discrepancy

- TMM field is prescribed on the surface and this is unphysical.
- Comsol the field propagates through a slit and the fields interact with the slit.

Nonlinear Photonics with MDS₃

$$\mathbf{P}_{\text{NL}} = \varepsilon_0 \chi^{(2)} \mathbf{E} \mathbf{E} + \varepsilon_0 \chi^{(3)} \mathbf{E} \mathbf{E} \mathbf{E} + \dots$$

$$\nabla \times \nabla \times \mathbf{E} = -\mu_0 \left(\varepsilon_0 \frac{\partial^2 \mathbf{E}}{\partial t^2} + \frac{\partial^2 \mathbf{P}_L}{\partial t^2} + \frac{\partial^2 \mathbf{P}_{\text{NL}}}{\partial t^2} \right)$$

$$\nabla(\nabla \cdot \mathbf{E}) - \nabla^2 \mathbf{E} = -\mu_0 \left(\varepsilon_0 \frac{\partial^2 \mathbf{E}}{\partial t^2} + \frac{\partial^2 \mathbf{P}_L}{\partial t^2} + \frac{\partial^2 \mathbf{P}_{\text{NL}}}{\partial t^2} \right)$$

Nonlinear absorption
And Nonlinear refraction
Applications (Optical limiting
and Switching)

$$E(Z, r, t) = E_0(t) \frac{w_0}{w(Z)} \exp \left(-\frac{r^2}{w^2(Z)} + i \frac{\pi r^2}{\lambda R(Z)} + i\phi \right)$$

$$Z_0 = \frac{\pi w_0^2}{\lambda}$$

For CW $E_0(t) \rightarrow E_0$

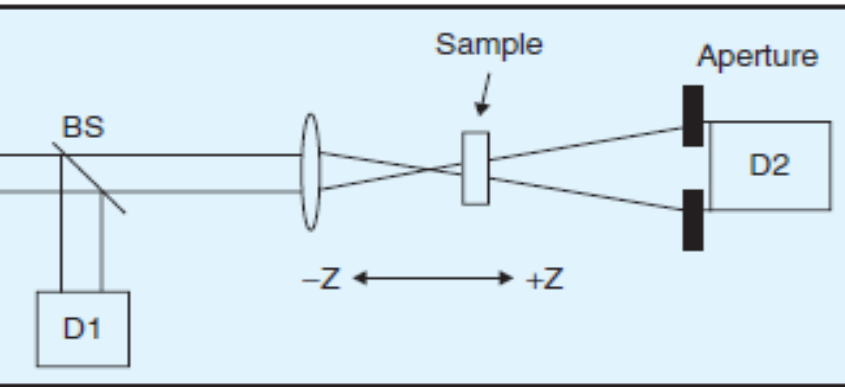
$$\chi^{(3)} \propto n_2 + i\beta$$

NL index change

NL (two photon) absorption

Z scan technique

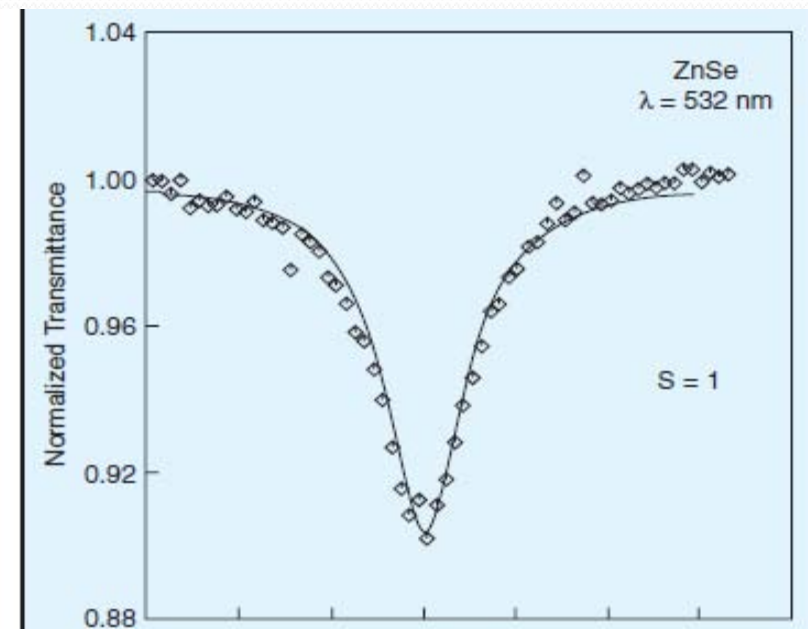
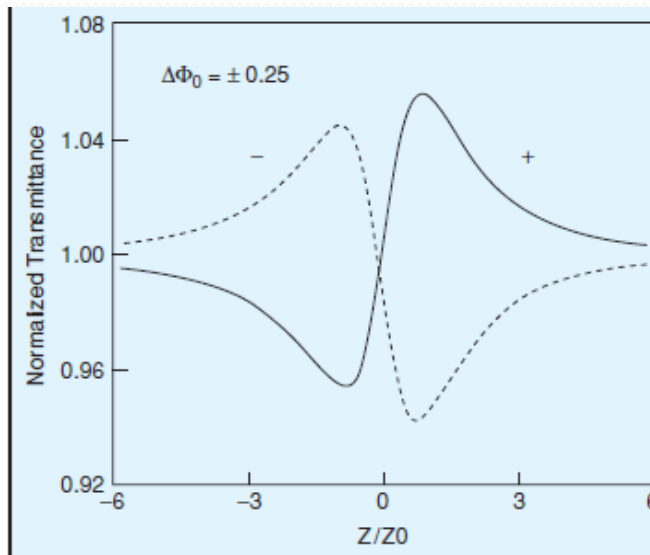
Developed for homogenous material,
reliable for the determination of β and n_2



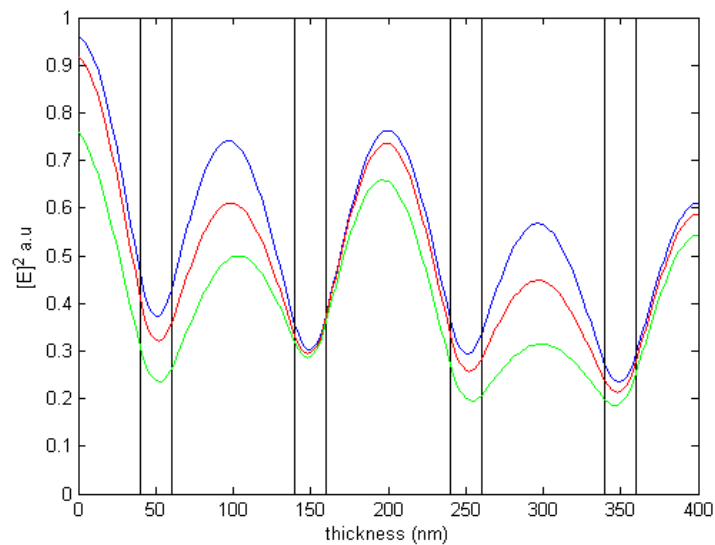
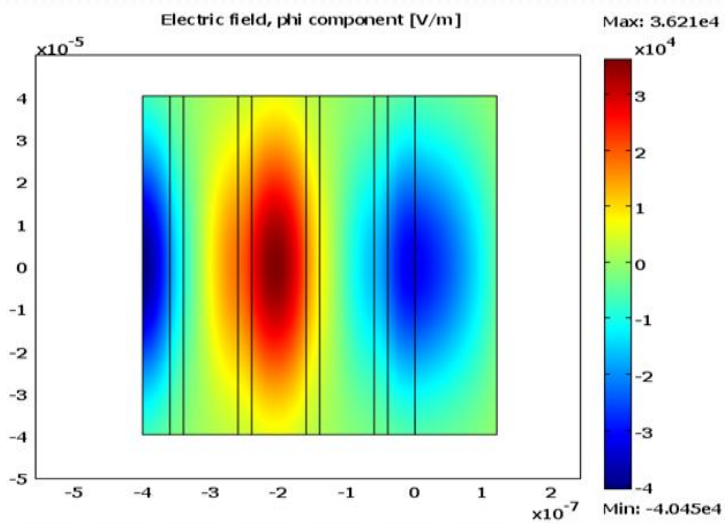
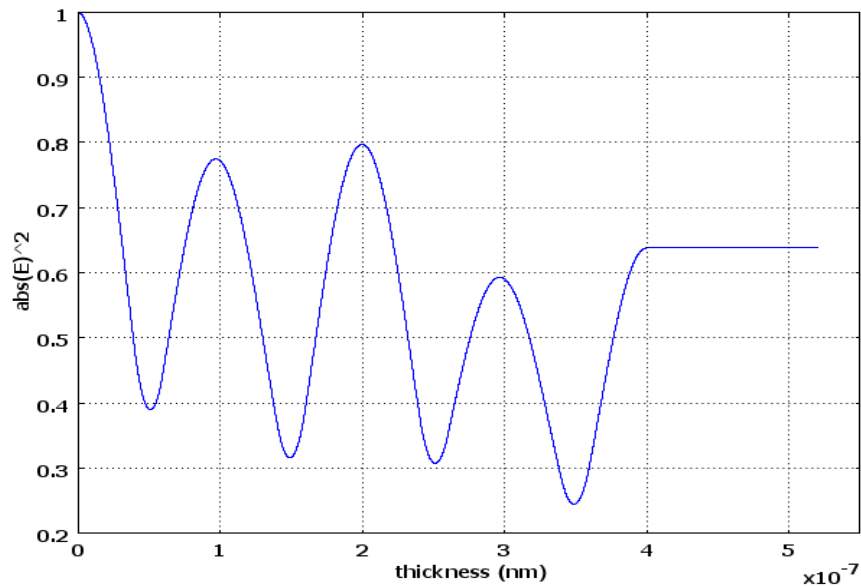
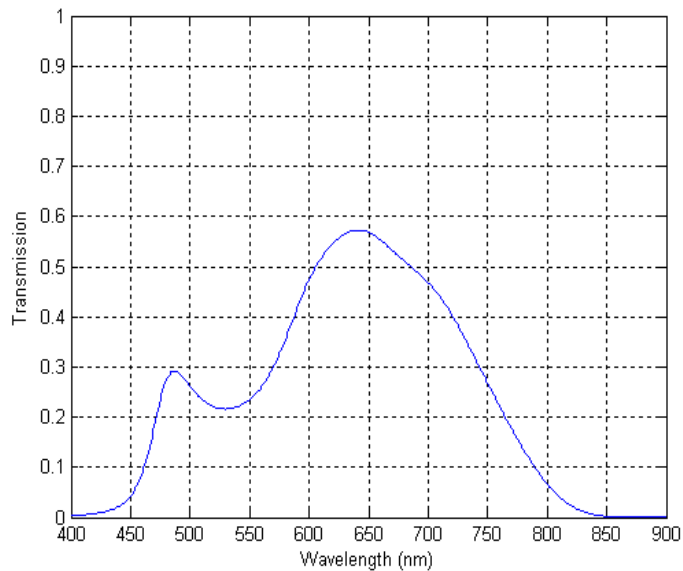
M. Sheik-Bahae, A. A. Said, T. Wei, D. J. Hagan, and E. W. Van Stryland, "Sensitive measurement of optical nonlinearities using a single beam," IEEE J. Quantum Electron. **26**, 760–769 (1990).

$$P_T(\Delta\Phi_0(t)) = c\epsilon_0 n_0 \pi \int_0^{r_0} |E_a(r, t)|^2 r dr$$

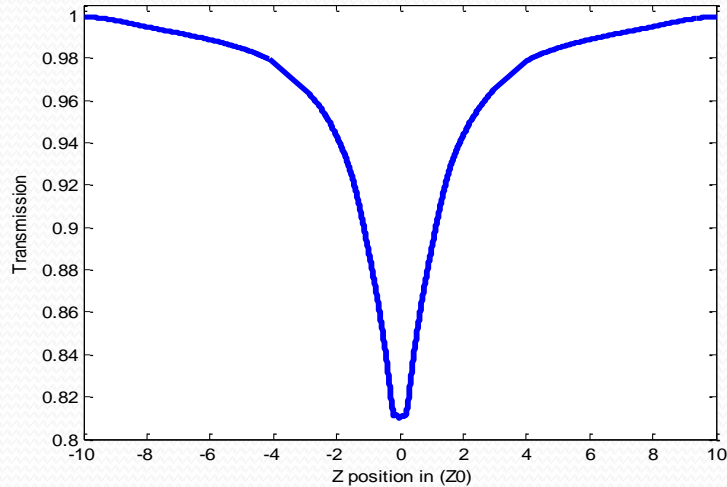
$$E_l(z, r, t) = E(z, r, t) e^{-\alpha L/2} e^{i\Delta\phi(z, r, t)}.$$



Results for MDS₃



Open Aperture Z scan Result



$$\beta = 4.75 \times 10^{-6} \text{ cm/W}$$

$$n_2 = 2 \times 10^{-11} \text{ cm}^2/\text{W}$$

$$w_0 = 20 \mu\text{m}$$

$$T(Z) = \frac{1}{U} \int_{-\infty}^{+\infty} dt \int_0^{r_a} r dr |E_a(Z, r, t, d)|^2$$

$$T(Z) \cong 1 - \frac{4\Delta\phi_0 x}{(x^2 + 9)(x^2 + 1)}$$

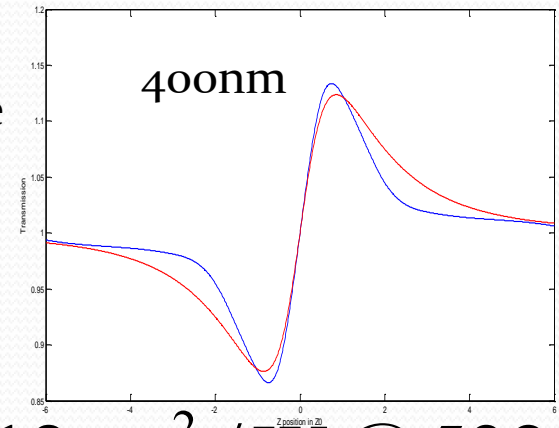
-Simulation of a 1D photonic band gap device such as our MD stack usually includes the losses due to internal multi-interference and back reflections, which contributes to the absorption within each layer .

-Considers transverse effects important in describing the beam profile are neglected [10]. These transverse effects are important for experimental purposes.

-Significant nonlinearity and realistic input beams,

Check for purely nonlinear refractive material,

FEM:blue
ANA:red



$$n_2 = 9e-12 \text{ cm}^2/\text{W} @ 532 \text{ nm}$$

Summary and conclusions

Super-resolution is achieved at various wavelengths with MDS.

Compared **the TMM and the FEM** for Transmission, and Super-resolution. We find that even though both methods yield the same results for Transmission, the standard TMM method fails to accurately predict Super-resolution.

Simulated the propagation of a typical **Gaussian beam** through a nonlinear MDS. The output of this simulation has been used to model the standard CW Z scan experiment, and the results agree very well with the Z scan theory

Future Work : Include temperature dependence for the permittivity and solve a transient problem.

Some References

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- [7] J.W. Haus, N. Katte, J. B. Serushema and M. Scalora, "Metallodielectrics as Metamaterials," "SPIE Optics and Photonics Conference, to appear (2010).
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Simulation Details

****Nonlinear Optics Simulation****

Number of Mesh points =4305

Number of Mesh elements 4160

Number of degrees of Freedom=33858